

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of: MANFRED HORSTMANN **ROLF STEPHAN** KARSTEN WIECZOREK STEPHEN KRUEGEL

Serial No.: 09/847,622

Filed: May 2, 2001

For: FIELD EFFECT TRANSISTOR WITH **REDUCED GATE DELAY AND** METHOD OF FABRICATING THE SAME

Examiner: Unknown

Group Art Unit: 2812

Att'y Docket: 2000.064200/DE0053

PRELIMINARY AMENDMENT

	CERTIFICATE OF MAILING 37 C.F.R 1.8	
Assistant Commissioner for Patents Washington, D.C. 20231 Sir:	I hereby certify that this correspondence is being dep Postal Service with sufficient postage as First Class addressed to: Assistant Commissioner for Patents, 20231, on the date below: October 1, 2001 Date	Mail in an envelope
Please amend the above-referenced patent application as follows:		C 2 O
IN THE CLAIMS:		ECEINF 2800 M
Please amend claim 1 as follows:		MAIL R
1. (Amended) A transistor, comprising:		ROOM

IN THE CLAIMS:

a substrate;

an active region defined in said substrate;

a gate insulation layer formed above said active region; and

a gate electrode formed above said gate insulation layer, said gate electrode having a middle portion located over the active region, said middle portion having a gate